Accepted Manuscript

Title: Sustainable degradation of carbon tetrafluoride to non-corrosive useful products by incorporating reduced electron mediator within electro-scrubbing

Authors: G. Muthuraman, A.G. Ramu, Y.H. Cho, E.J. McAdam, I.S. Moon

PII: DOI: Reference: S1226-086X(18)30095-9 https://doi.org/10.1016/j.jiec.2018.02.025 JIEC 3885

To appear in:

Received date:	27-12-2017
Revised date:	5-2-2018
Accepted date:	10-2-2018

Please cite this article as: G.Muthuraman, A.G.Ramu, Y.H.Cho, E.J.McAdam, I.S.Moon, Sustainable degradation of carbon tetrafluoride to non-corrosive useful products by incorporating reduced electron mediator within electro-scrubbing, Journal of Industrial and Engineering Chemistry https://doi.org/10.1016/j.jiec.2018.02.025

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting proof before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.



Journal of Industrial and Engineering Chemistry, Volume 63, 25 July 2018, Pages 275-280 DOI:10.1016/j.jiec.2018.02.025

Sustainable degradation of carbon tetrafluoride to non-corrosive useful products by incorporating reduced electron mediator within electroscrubbing

G. Muthuraman^a, A.G. Ramu^a, Y. H. Cho^b, E.J. McAdam^c, and I. S. Moon^a*

^aDepartment of Chemical Engineering, Sunchon National University, #255 Jungangno, Suncheon 540-742, Jeollanam-do, Rep. of Korea.

^bKorea Atomic Energy Research Institute, Yuseong P.O Box 105, Daejeon, Rep. of Korea

^cCranfield Water Science Institute, Cranfield University, Building 39, MK43 0AL,

UK

*Corresponding Author: Tel: +82 61 750 3581; Fax: +82 61 750 3581 E-mail: ismoon@sunchon.ac.kr

Graphical Abstract



Synopsis: Ethanol generation was established during the degradation of CF_4 by mediated electrocatalytic reduction using electrogenerated $Cu^{1+}[Ni^{2+}(CN)_4]^{1-}$ at electro-scrubbing process.

Highlights

- A Cu²⁺[Ni²⁺(CN)₄] complex was established for carbon tetrachloride degradation to non-corrosive useful product
- ORP and ESR results demonstrated Cu¹⁺ formation at cathodic half-cell during electrolysis
- Mass transfer analysis identifies rate limiting behavior and routes to optimization
- Ethanol found to be a main product in the degradation of CF₄ my MER at electroscrubbing

Abstract

The degradation of CF₄ gas using existing technologies produces other types of greenhouse gas (CO₂) and corrosive side products. The main aim of this study is to degrade CF₄ gas at room temperature into useful products without producing corrosive side products by mediated electrochemical reduction (MER) process using an electrogenerated $Cu^{1+}[Ni^{2+}(CN)_4]^{1-}$ mediator. Initial studies on the electrolytic reduction of the hetero-bimetallic complex in catholyte solution at anodized Ti cathode was monitored by oxidation/reduction potential (ORP) variation whether the Cu^{2+} or Ni²⁺ was reduced in the $Cu^{2+}[Ni^{2+}(CN)_4]^{1-}$ formation. The concentration variation of $Cu^{1+}[Ni^{2+}(CN)_4]^{1-}$ during CF₄ injection demonstrated the

degradation of CF₄ followed the MER by electrogenerated Cu¹⁺[Ni²⁺(CN)₄]¹⁻. Maximum removal efficiency of CF₄ using electroscrubbing process was 96% at room temperature. Through the variation in gas phase parameters, the gas phase mass transfer coefficient was calculated that can facilitate scale up the developed process. Fourier transform infrared spectroscopy analysis in both the gas and solution phases showed that CH₃CH₂OH was the main product that formed during the removal of CF₄ by electrogenerated Cu¹⁺[Ni²⁺(CN)₄]¹⁻ at electroscrubber along with a small amount of CF₃CH₃ intermediate. Importantly, this mechanism also avoided formation of the corrosive product HF.

Keywords: Hetero-bimetal, MER, CF₄ degradation; Ethanol formation

1. Introduction

Both etching and cleaning steps in semiconductor manufacturing make use of perfluoro gases, such as CF₄, NF₃ and SF₆, which possess high global warming potential (GWP) [1]. Consequently, growth in electronic equipment demand is driving considerable increase in GWP through the fugitive release of perfluo gases into the environment. Of particular concern is CF₄ which has 6500 time GWP of CO₂ [2]. However, there are currently only a limited number of abatement technologies for perfluoro gases, which constitutes an extremely challenging separation. The two primary existing technologies are combustion and plasma arc [3-6]. Whilst the plasma etching technique could potentially be used in the electronic manufacturing industries, plasma will not typically achieve complete perfluoro gas degradation which results in formation of byproducts, notably another greenhouse gas, CO₂, and its derivatives (COF₂, CO, H₂O), with HF depending on the carrier gas [7-10]. Catalytic

combustion has also attracted considerable interest [11,12], particularly hydrolytic combustion because of its lower Gibbs free energy (-150 kJ/mol). Unfortunately, one of the final products obtained is highly corrosive HF, as shown in reaction 1, which leads to catalyst deactivation [13]. Also, another product in the catalytic combustion in the CF₄ decomposition process is CO₂, thereby further exacerbating greenhouse gas production.

$$CF_4 + 2H_2O \longrightarrow CO_2 + 4HF (\Delta G = -150 \text{ kJ/mol}) [11,12] --- (1)$$

The degradation of chloro fluoro carbons (CFCs) to mostly non-fluoro compounds has been achieved by electrochemical technique at room temperature without producing final products that contribute to greenhouse effects [14-16]. Copper supported gas diffusion electrode resulted in methane in degradation of CClF₃(CFC-13), and on Ag-supported gas diffusion electrode to form CHF₃ [14]. The degradation of many CFCs have been performed in solution phase especially through direct electrochemical reduction on different metal electrodes in acetonitrile [17] and DMF [18] to produce, CF₂CF₂, CH₂F₂, CH₃F, CF₂CFCl, and CHCF₃, as the main products, which are used as raw materials in the production of polymers and refrigerants. A methanol/water solvent mixture was also demonstrated to degrade CFC-11 and CFC-113 using a Pb cathode with a Pd containing gas diffusion anode by constant potential electrolysis, where complete or partially dehalogenated products were achieved depending on the Pd contents [19]. To improve understanding, fundamental electrochemical studies were performed on selective site-specific PFC compounds, which showed that the reduction reaction follows a radical reaction with the formation of a carbanion with subsequent oligomeric products, such as C₃H₈, C₃F₈, and CH₄ from CF₄ etc [20]. Most electrochemical studies on CFC degradation were performed in non-aqueous media or a combination of non-aqueous and aqueous solvents using electrochemical analyzer such as CV or constant potential electrolysis;

none were performed in only aqueous medium and a constant current electrolysis in the CFCs or CF_4 degradation process. Recently, CF_4 removal was reported using a mediated electrochemical reduction (MER) in aqueous KOH medium at room temperature by the electrochemically generated mediator Co^{1+} in an electro-scrubbing process [21]. Though, the main focus was development of room temperature removal of CF₄ by electroscrubbing (for the first time), the product found in the Co^{1+} MER of CF_4 were HF and ethanol [21]. The HF formation not only constitutes an environmental concern but may also reduce the pH of the electrolyte in continuous electro-scrubbing process, which will inactivate mediator generation, subsequently limiting CF₄ removal. Consequently, provided HF formation can be avoided, sustained CF₄ degradation could be achieved, coupled with the generation of ethanol that could be conceived as a sustainable high-value end product. One alternative could be utilization of a binary metal complex or bimetallic complex in the CF₄ degradation process. Note that to minimize catalyst deactivation in catalytic combustion process, a binary metal catalyst was attempted to degrade CF₄ by hydrolytic combustion process, with the idea of C-F bond breaking at the Lewis-acid catalysts to form metal fluorides, which was hydrolyzed, and made possible the assessment of various bimetal combinations. The study found that Ga-Al and Ni-Al oxide catalysts were stable from HF deactivation [22-24]. In another study, the CF4 was converted to CO₂ with minimal deactivation (by HF formation) of the γ -Al₂O₃ catalysts by the addition of Zn, Ni, Mg, Sr, and Ba metals [7]. A stable catalyst was achieved in catalyst combustion process using Ce/Al₂O₃ binary catalyst but that was not effective in the removal of CF₄ [24].

In the present investigation, it is asserted that the hetero-bimetallic complex $Cu^{2+}[Ni^{2+}(CN)_4]$ can be used as a mediator precursor in the degradation of CF₄ gas to form a

useful end product and without the production of harmful sideproducts like HF . A constant current method was used to generate low valent active mediator generation in 10 M KOH medium at cathodic half-cell in a divided electrolytic cell to generate a low valent active mediator. An anodized Ti or TiO₂ cathode was used for the electrolytic reduction of $Cu^{2+}[Ni^{2+}(CN)_4]$ in 10 M KOH. The oxidation/reduction potential (ORP) of Cu^{2+} and Ni^{2+} in a dissolved electrolyzed solution during electrolysis were taken as an indication and quantification by a potentiometric titration separately for the formation of a low oxidation state active mediator. In addition, electron spin resonance (ESR) spectroscopy was used to support the differentiation of Cu^{2+} or Ni^{2+} reduction in an electrolyzed solution. CF₄ degradation was carried out within an electro-scrubber, where CF₄ was fed continuously at a controlled rate and concentration through the bottom of the scrubber and the spent hetero-bimetallic complex was then sent to a cathodic half-cell to generate a low oxidation state active mediator. The CF₄ removal efficiencies were monitored using online Fourier transform infrared (FTIR). Solution phase and gas phase analyses were conducted to determine the final product.

2. Materials and Methods

2.1 Preparation of mediator precursor.

The hetero-bimetallic $Cu^{2+}[Ni^{2+}(CN)_4]$ was prepared using the literature procedure [25]. In brief, $Cu^{2+}(NO_3)_2.3H_2O$ and $[Ni^{2+}(CN)_4]^{2-}$ were added to 200 ml of water at a Cu^{2+} to Ni^{2+} mole ratio of 1:4. A light blue precipitate formed slowly with constant stirring, which was separated by filtration, washed several times with water and dried in a desiccator prior to use. $[Ni^{2+}(CN)_4]^{2-}$ was prepared using the existing literature procedure [26]. Briefly, $Ni^{2+}(NO_3)_2.6H_2O$ was taken at a 1:4 mole ratio (Ni^{2+} to cyanide) to KCN, which was already

dissolved in 200 ml cooled water (extreme care was taken when handling the KCN during complex preparation because it is highly dangerous to humans). To this reaction solution, an equal volume of chilled alcohol was then added. The resulting thin orange platelets were filtered rapidly, washed with cold alcohol, recrystallized in ethanol, dried in a vacuum desiccator, and stored in an air-tight brown bottle.

2.2 Setup and procedure for mediator generation and degradation.

A divided flow-through electrolytic cell was used, as in a previous publication [21], under suitable additional conditions (Fig.1). Briefly, a 4 cm² working electrode area capacity thin layer plate and frame divided cell (divided with Nafion324) was connected to the catholyte (200 ml of mediator precursor in 10 M KOH) and anolyte (200 ml of 5 M H₂SO₄) glass tanks through polycarbon tubing to allow the anolyte and catholyte to circulate (using peristaltic pumps) through the respective anode and cathode compartments. The electrolysis experiments were conducted in constant current mode using a DC power supply. All solutions were prepared using reverse osmosis purified water (Human Power III plus, South Korea) with a resistivity of 18 M Ω -cm.

For the electro-scrubbing process, a 50 cm² electrode area capacity divided plate and frame electrochemical cell was connected to a 40 cm high and 5.5 cm (i.d) column packed with 1 cm² of Teflon tubes as the packing material on top of the catholyte tank (1 L capacity), as in Fig.1 and the previous published literature [21]. The electrolyte solutions (500 ml) were circulated continuously to flow through the electrolytic cell at different flow rates (1 to 5 L min⁻¹) using magnetic pumps. The catholyte solution as a scrubbing solution (electrolyzed mediator in a KOH solution) was pumped separately into the scrubber column at a flow rate of 3 L min⁻¹. CF₄ gas (from RIGAS (1000 ppm), Korea) and N₂ mixtures, which were obtained by the

controlled mixing of air and CF₄ gas using mass flow controllers (MFCs), were introduced to the bottom of the scrubber at a set gas flow rate. An online gas analyzer (FTIR) was attached to the scrubber exit to facilitate the instantaneous degradation measurements. Before each electrolysis experiment, the Ti electrode (cathode) was pretreated separately by an anodization process in 0.1 M KNO₃ at a constant current of 1 A for 5 min. All experiments were conducted at room temperature (20 ± 2 °C).

2.3 Quantification of mediator ion.

The electrolyzed solution containing the Cu¹⁺ or Ni¹⁺ concentrations were determined using a potentiometric titration method [21]. In the present case, the electrolyzed sample solution was titrated against a standard $Fe^{3+}(CN)_6^{3-}$ (From Sigma Aldrich, USA) solution (0.001 M) and the potential variation was monitored using an ORP (oxidation/reduction potential) electrode (EMC 133, 6 mm Pt sensor electrode and Ag/AgCl reference electrode containing a gel electrolyte) connected to an iSTEK multimeter. The initial catholyte (Cu²⁺[Ni²⁺(CN)₄]) solution potential was approximately -170 mV, which was then decreased as electrolysis progressed at a constant current density. By titration against 0.001 M [Fe³⁺(CN)₆]³⁻, the initial ORP value showed that the Fe³⁺ concentration can be used to derive the concentration of Cu¹⁺.

2.4 Analysis.

Gas phase online analysis was performed using an online FTIR gas analyzer (from MIDAC Corporation, USA). Solution phase sample analysis was carried out by attenuated total reflectance – Fourier transform infrared (ATR-FTIR, Thermo scientific, Nicolet iS5, USA) spectroscopy using a 2 μ L drop of the reaction sample on the diamond sample holder to derive

the products. To understand the change in oxidation state of the metal ion and its influence in CF_4 degradation process, ESR spectroscopy was performed with focused light of a 1000 W high-pressure Hg lamp through an aqueous filter. The ESR spectra were measured at the X-band (~9.7 GHz) and under liquid nitrogen conditions (77 K) with a Bruker EMX model spectrometer.

3. Results and discussion

3.1 Generation of mediator.

Fig. 2A (curve a) shows the changes in ORP changes during the electrolysis of mediator precursor containing Cu²⁺[Ni²⁺(CN)₄] the electrolyzed solution. The ORP value of the $Cu^{2+}[Ni^{2+}(CN)_4]$ electrolyzed solution was reached ~ - 500 mV from -50 mV after 4h electrolysis could be Cu²⁺ to Cu¹⁺ reduction. In order to crosscheck whether the Ni²⁺ reduction, though the Ni¹⁺ ORP value found -800 mV [21], occurred, the ORP value of only [Ni²⁺(CN)₄]²⁻ during electrolytic reduction was compared (Fig.2A curve b), where the ORP value reached immediately to -700 mV indicating that Cu²⁺ is reduced instead of Ni²⁺ in the heterobimetallic complex $(Cu^{2+}[Ni^{2+}(CN)_4])$. To confirm whether Cu^{2+} is reduced, the electrolyzed solution of Cu²⁺[Ni²⁺(CN)₄] was analyzed by ESR and the results are shown in Fig.2B. The ESR spectra showed a typical pattern for the polycrystalline Cu^{2+} ion having near axial symmetry with g_{xx} \approx g_{vv} (~2.04) and g_{zz} (~2.26) and A_{xx} \approx A_{vv} (~ 35 G) and A_{zz} (~190 G) values. The g values and A_{xx} , A_{yy} and a large A_{zz} value, which is greater than 140 G confirmed the Cu²⁺ complex with a square-planar geometry [27] (Fig.2B curve a). On the other hand, its reduced monovalent Cu¹⁺ species was ESR inactive. Therefore, at the same time, the electrolyzed $Cu^{2+}[Ni^{2+}(CN)_4]$ samples showed a reduced intensity without a change in the symmetrical

values indicating Cu^{1+} formation with square planar geometry (Fig.2B curve b). Interestingly, the Cu^{1+} concentration was increased with increasing electrolysis time (Fig.3), which was derived by potentiometric titration. The Cu^{1+} concentration can be generated electrochemically a maximum of 3.1 mM in 5 h electrolysis time in the bimetallic complex ($Cu^{2+}[Ni^{2+}(CN)_4]$) under the given conditions.

3.2 CF₄ degradation by MER.

Once the Cu¹⁺ concentration reached approximately 3 mM by electrolysis, the electrolyzed solution of $Cu^{1+}/Cu^{2+}[Ni^{2+}(CN)_4]$ was pumped into the scrubbing column through the top of the scrubbing column. Subsequently, 10 ppm of CF_4 was injected at 0.2 L min⁻¹ into the bottom of the scrubbing column, while electrolysis was continued to regenerate the Cu¹⁺. Fig. 4 shows the results obtained under these conditions, where shows a decrease in Cu¹⁺ concentration from 3.1 mM to 2.1 mM while inject 10 ppm of CF₄ into the scrubber that then decreases further to 1.2 mM in 1h CF₄ removal time. At the same time, there was almost 96% of feed CF₄ removed initially and keep maintained around 93% removal during studied time 1 h (inset figure). This explains CF₄ removal at room temperature by the electrogenerated Cu¹⁺[Ni²⁺(CN)₄]¹⁻ is possible. This 96% CF₄ removal is not simply by absorption in to 10 M KOH solution because, CF₄ absorption into a 10 M KOH solution reached saturation in 5 min [21]. The Cu^{1+} concentration variation during the CF_4 removal process suggests that the CF_4 removal reaction follows the MER by electrogenerated $Cu^{1+}[Ni^{2+}(CN)_4]^{1-}$. The Cu^{1+} concentration started increased once the CF₄ feed stopped confirms the CF₄ removal sustainable by continuous generation of Cu¹⁺ electrochemically.

Removal of CF_4 was undertaken at different gas flow rates (Fig. 5). At the lowest gas flow rate of 0.2 L min⁻¹, CF_4 removal was almost 100%. However, this decreased to 26% with

increasing gas flow rates to 2 L min⁻¹. This implies that the generation rate of Cu¹⁺ is insufficient to sustain CF₄ removal as CF₄ loading is increased. Mass transfer analysis confirmed that above the flow rate of 0.2 L min⁻¹, a finite conversion rate of 13 to 18 µg CF₄ min⁻¹ was achieved independent of gas flow rate (Figure 6 curve a). When the rate of mass transfer in gas-liquid systems is independent of gas velocity, the process can be described as liquid-phase controlled, which is characteristic of separations comprising solutes with limited solubility, such as CF₄ [28]. In this study, the reduction of CF₄ could have been within the liquid film or within the bulk, in which case CF₄ absorption would have been facilitated without electrogenerated mediator (Fig.1 in ref. 21). Liquid-phase resistance to mass transfer may therefore be enhanced through optimizing the ratio between the scrubber recycle rate (or gas-to-liquid ratio) and electrochemical recycle rate, to increase the rate of reaction, and obviate resistance imposed by the low solubility of the non-reduced primary solute. Feed concentration was increased from 10 ppm to 30 ppm CF₄, which reduced CF₄ removal efficiency from 95% to 30% (Fig.7). The time to steady-state increased to nearly 45 min at 30 ppm, which is ascribed to the sudden void of electrogenerated Cu¹⁺ through reaction with the increased CF₄ injection. Mass transfer analysis demonstrated a consistent rate of reaction at steady-state, which indicates that CF₄ degradation was zero order with respect to concentration (Figure 6 curve b), such that the rate of separation from the gas phase will be dependent upon the concentration of free reactant Cu^{1+} in the liquid phase.

3.3 Product analysis.

The comparative in-situ gas FTIR spectra (Fig.8 curve e) confirms the formation of CH_3CH_2OH during the degradation of CF_4 by MER process, where the standard CF_4 and

CH₃CH₃OH were compared (Fig.8 curve a & b). At initial degradation process, there was observed no peak at CH₃CH₂OH frequency region (Fig.8 curve d) but CH₃CH₂OH peak found during its evolution timings (Fig.8 curve e) confirms the CH₃CH₂OH formation but, according to inset Fig.4, almost 96% CF₄ removal was achieved from the beginning of the removal process. Also, no products were observed at the scrubber in the first 30 min (Fig.SI 1curve a). After 30 min, a huge concentration of ethanol (CH₃CH₂OH) suddenly emerged at the scrubber exit at approximately 250 ppm (Fig.SI 1 curve a). In a similar time interval, trifluoroethane (CH₃CF₃) began to exit around 10 ppm (Fig.SI 1 curve b). Note that ethanol and HF were produced from the beginning of the removal process while the electrogenerated Co^{1+} mediator was used to remove CF₄ gas [21]. The CF₄ removal process followed mediated degradation to soluble products that exited after a saturation point was attained, which could explain the late exit of CH₃CH₂OH and CH₃CF₃. Surprisingly, no HF gas was coming out of the scrubber or exit gas (inset figure of Fig.SI 1) could be due to CH₃CF₃ intermediate formation by heterobimetallic complex $(Cu^{1+}[Ni^{2+}(CN)_4]^{1-})$. Noteworthy that in case of only electrogenerated mediator $[Ni^{1+}(CN)_4]^{3-}$, the CF₄ removal followed COF₂ intermediate pathway [21] to produce ethanol. Also, the CH₂CH₂OH formation found only at 0.2 L/min gas flow rate and at higher gas flow rates 1 and 2 L min⁻¹, there found no CH₃CH₂OH peak but CH₃CF₃ peak appeared (Fig.SI 2 & 3) at its respective frequency region additionally support the CH₃CH₂OH formation only at low gas flow rate and also the reaction stopped at intermediate formation. The scrubbing solution underwent an ATR-FTIR analysis after the electro-scrubbing process was completed and reaction solution showed only CH₃CH₂OH present (-O-H and -C-O stretching frequencies well matched with the instrument library CH₃CH₂OH sample) in solution (Fig. SI 4), confirming that the reaction product is CH₃CH₂OH. Many electrochemical

reports have shown that CFCs form CH₄ and fluorine-reduced derivatives, such as CF₃CH, CH₂F₂, CH₃F, and CF₂CFCl [17-20] but, there are no reports on the formation of CH₃CH₂OH during the degradation of CF₄. Recently, direct ethanol formation was observed on a copper electrode during the reduction of CO₂ through carbon dioxide dimer formation [29,30]. Similarly, a carbon tetrafluoride dimer could have formed via the electrogenerated Cu¹⁺, which might have easily hydroxylated to ethanol, because the scrubbing solution is 10 M KOH, as shown by the proposed scheme 1. The possibility of dimerization was confirmed by the additional product CF₃CH₃ (Fig.8 curve b) found at the scrubber exit, which may be due to incomplete reaction or intermediate formation.

4. Conclusions

Electrogenerated $Cu^{1+}[Ni^{2+}(CN)_4]^{1-}$ successfully degraded CF₄ to ethanol without forming HF at room temperature. The electrogeneration of Cu^{1+} from the hetero-bimetallic complex of $Cu^{2+}[Ni^{2+}(CN)_4]$ was identified by ORP variation and confirmed the same by ESR spectroscopy analysis. The Cu^{1+} concentration variation during the injection of CF₄ into the scrubber column or the CF₄ removal process confirmed the degradation of CF₄ follows MER process. The online gas phase and offline solution phase FTIR analyses results confirmed that CH₃CH₂OH is a final product along with an intermediate or incomplete product CF₃CH₃ without corrosive product HF during the degradation of CF₄ using the electrogenerated $Cu^{1+}[Ni^{2+}(CN)_4]^{1-}$ in a highly KOH medium. Independent of mass transfer coefficient with feed CF₄ concentration confines the degradation follows zero order kinetics and chemical reaction controlled process, which enables to help scale-up the process.

ACKNOWLEDGEMENT

This investigation was supported by the National Research Foundation of Korea (NRF) funded by Ministry of Engineering Science and Technology (MEST) from the Korean government (Grant No. NRF-2017R1A2A1A05001484).

REFERENCES

- A.R. Ravishankara, S. Solomon, A.A. Turnipseed, R.F. Warren, Science 259 (1993) 194-199.
- [2] W.-T. Tsai, H.-P. Chen, W.-Y. Hsien, J. Loss Prevent. Proc. 15 (2002) 65-75.
- [3] C. Rittmeyer, J. Vehlow, Chemosphere 26 (1993) 2129-2138.
- [4] C.W. Lee, J.V. Ryan, R.E. Hall, G.D. Kryder, B.R. Springsteen, Combust. Sci. Technol. 116-117 (1996) 455-478.
- [5] H.M. Lee, M.B. Chang, R.F. Lu, Ind. Eng. Chem. Res. 44 (2005) 5526-5534.
- [6] A. Gal, A. Ogata, S. Futamura, K. Mizuno, J. Phys. Chem. A 107 (2003) 8859-8866.
- [7] X.-F. Xu, J.Y. Jeon, M.H. Choi, H.Y. Kim, W.C. Choi, Y.-K. Park, J. Mol. Catal. A: Chem. 266 (2007) 131-138.
- [8] M.S. Gandhi, Y.S. Mok, J. Environ. Sci. (Beijing, China) 24 (2012) 1234-1239.
- [9] Narengerile, H. Saito, T. Watanabe, Plasma Chem. Plasma P. 30 (2010) 813-829.
- [10] H. Zhang, C.F. Ng, S.Y. Lai, Appl. Catal. B Environ. 55 (2005) 301-307.
- [11] X. Xu, X. Niu, J. Fan, Y. Wang, M. Feng, J. Nat. Gas Chem. 20 (2011) 543-546.
- [12] Y. Takita, M. Ninomiya, H. Miyake, H. Wakamatsu, Y. Yoshinaga, T. Ishihara, Phys. Chem. Chem. Phys. 1 (1999) 4501-4504.
- [13] M.M. Farris, A.A. Klinghoffer, J.A. RosSnl, D.E. Tevault, Catal. Today 11 (1992) 501-516.
- [14] N. Sonoyama, T. Sakata, Environ. Sci. Technol. 32 (1998) 375-378.
- [15] P.L. Cabot, L. Segarra, J. Casado, J. Electrochem. Soc. 151 (2004) B98-B104.
- [16] E.R. Wagoner, D.G. Peters, J. Electrochem. Soc. 160 (2013) G135-G141.
- [17] A. Schizodimou, G. Kyriacou, C. Lambrou, J. Electroanal. Chem. 471 (1999) 26-31.

- [18] E.R. Wagoner, J.L. Hayes, J.A. Karty, D.G. Peters, J. Electroanal. Chem. 676 (2012) 6-12.
- [19] P.L. Cabot, L. Segarra, J. Casado, Electrochem. Solid-State Lett. 6 (2003) B15-B18.
- [20] R.E. Taylor-Smith, D. Sayres, Proc. Electrochem. Soc. 99-8 (1999) 116-125.
- [21] G. Muthuraman, I.S. Moon, J. Hazard. Mater. 325 (2017) 157-162.
- [22] Z.M. El-Bahy, R. Ohnishi, M. Ichikawa, Appl. Catal., B Environ. 40 (2003) 81-91.
- [23] Y. Takita, C. Morita, M. Ninomiya, H. Wakamatsu, H. Nishiguchi, T. Ishihara, Chem. Lett. (1999) 417-418.
- [24] J.-Y. Song, S.-H. Chung, M.-S. Kim, M.-g. Seo, Y.-H. Lee, K.-Y. Lee, J.-S. Kim, J. Mol. Catal. A: Chem. 370 (2013) 50-55.
- [25] A.M. Chippindale, S.J. Hibble, E. Marelli, E.J. Bilbe, A.C. Hannon, M. Zbiri, Dalton T.
 44 (2015) 12502-12506.
- [26] W.C. Fernelius, J.J. Burbage, N.E. Ballou, Potassium tetracyanonickelate(II), in: Inorganic syntheses, John Wiley & Sons, Inc., 2007, pp. 227-228.
- [27] M.G. Savelieff, T.D. Wilson, Y. Elias, M.J. Nilges, D.K. Garner, Y. Lu, P. Natl. Acad. Sci. USA 105 (2008) 7919-7924.
- [28] P. Scharlin, R. Battino, J. Solution Chem. 21 (1992) 67-91.
- [29] Y. Song, R. Peng, D.K. Hensley, P.V. Bonnesen, L. Liang, Z. Wu, H.M. Meyer, M. Chi,C. Ma, B.G. Sumpter, A.J. Rondinone, Chemistry Select 1 (2016) 6055-6061.
- [30] K.P. Kuhl, E.R. Cave, D.N. Abram, T.F. Jaramillo, Energ. Environ. Sci. 5 (2012) 7050-7059.

Figure captions

Fig.1 Schematic experimental setup used to degrade CF_4 at wet-scrubber by electrochemically generated $Cu^{1+}[Ni^{2+}(CN)_4]^{1-}$

Fig.2 (A) Oxidation/reduction potential (ORP) variation during electrolysis of (a) 50 mM $Cu^{2+}[Ni^{2+}(CN)_4]$ and (b) 50 mM $[Ni^{2+}(CN)_4]^{2-}$ in 10 M KOH solution. Electrolysis conditions: Electrodes (4 cm²) = Pt (anode) and anodized Ti (cathode); Current density $- 30 \text{ mA cm}^{-2}$; Solution flow rate = 70 ml min⁻¹.

(B) ESR spectra of frozen $Cu^{2+}[Ni^{2+}(CN)_4]$ in a 10 M KOH solution (a) before and (b) after electrolysis. The electrolysis conditions were the same as in legend of Fig.2A.

- Fig.3 Formation efficiency of Cu¹⁺ from Cu²⁺[Ni²⁺(CN)₄] during electrolysis in 10 M KOH solution. The electrolysis conditions are the same as in the legend of Fig.2A..
- Fig.4 Cu^{1+} concentration variation during MER of CF₄ gas at electro-scrubbing by scrubbing a solution of electrolyzed $Cu^{2+}/Cu^{1+}[Ni^{2+}(CN)_4]^{1-/0}$ solution. Inst figure shows CF₄ degradation efficiency variation with time. Conditions: Feed concentration of CF₄ = 10 ppm; Gas flow rate = 0.2 L min⁻¹; Scrubbing solution flow rate = 3 L min⁻¹. Solution flow rate to electrolytic cell = 2 L min⁻¹; Current density = 30 mAcm⁻²; Electrodes area = 50 cm².
- Fig.5 Effect of the gas flow rate (mentioned in the figure) with time on the removal of CF_4 using electrogenerated $Cu^{1+}[Ni^{2+}(CN)_4]^{1-}$ in a 10 M KOH solution at electro-scrubbing. The remaining experimental conditions are the same as in the legend of Fig.4.
- Fig.6 Mass conversion rate with CF₄ feed concentration (a) and gas flow rate (b) during its degradation at electro-scrubbing by electrogenerated Cu¹⁺[Ni²⁺(CN)₄]¹⁻ in 10 M KOH solution. The electrolysis and electroscrubbing experimental conditions are the same as

in the legend of Fig.4.

- Fig.7 Effect of the CF₄ feed concentration variation with time on its removal by electrogenerated Cu¹⁺[Ni²⁺(CN)₄]¹⁻ in 10 M KOH solution by electro-scrubbing. The remaining experimental conditions are the same as in the legend of Fig.4.
- Fig.8 Real time FTIR spectra during the removal of CF₄ at different conditions for product CH₃CH₂OH identification: (a) Reference FTIR for CF₄; (b) Reference FTIR for CH₃CH₂OH; (c) During direct feed on CF₄; (d) During the MER of CF₄ at 30 min; (e) During the MER of CF₄ at 60 min. The remaining experimental conditions are the same as in the legend of Fig.4.

Figures

Fig.1





Scheme 1 Plausible reaction pathway for CF₄ degradation to ethanol